



Further improvement of the TC performances

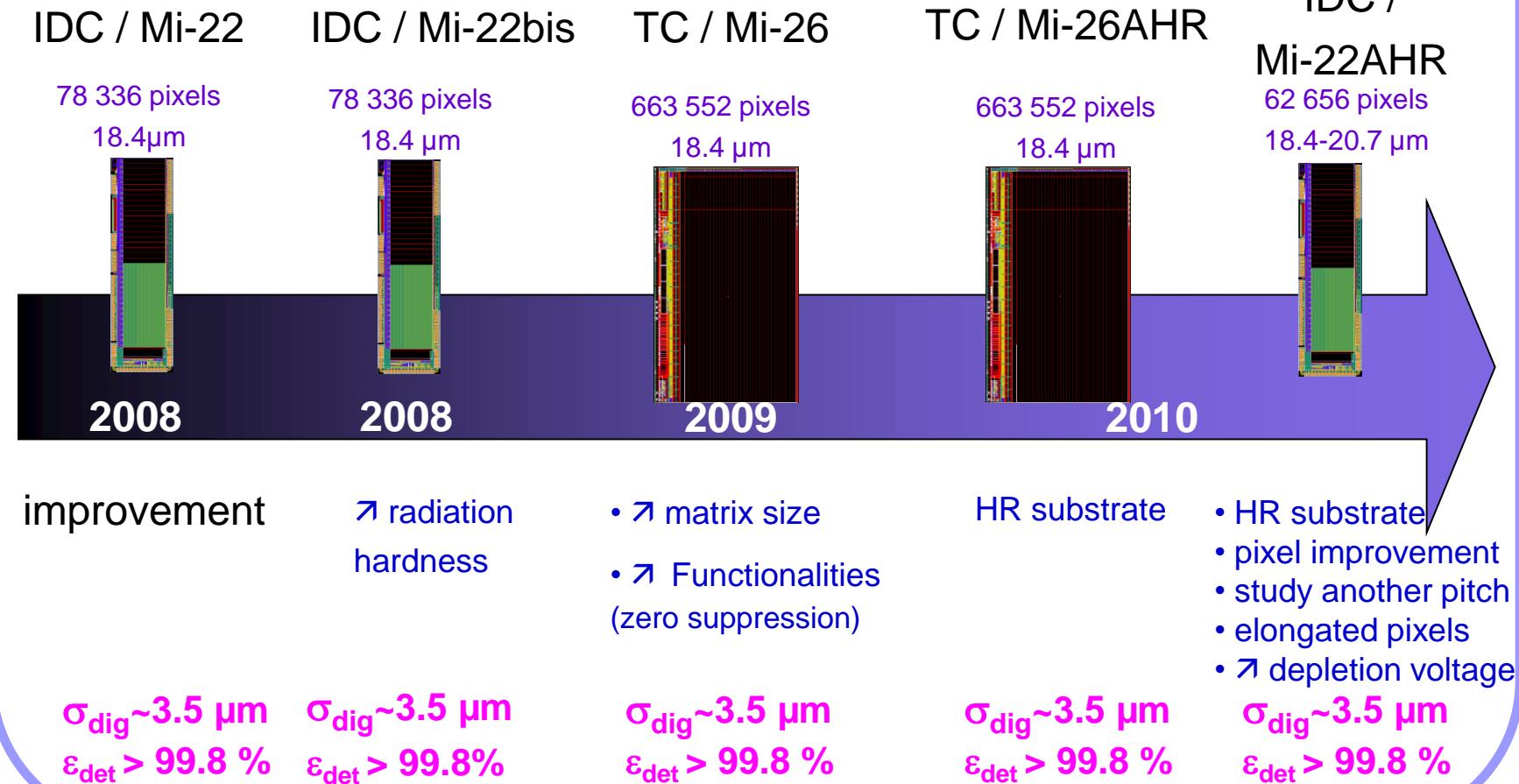
Marie GELIN on behalf of IPHC - Strasbourg and IRFU – Saclay

- Investigation of a new substrate (High Resistivity)
- Beam test preliminary results on TC (Telescope Chip) HR and IDC (Intermediate Digital Chip) HR
- Extra-uses of those chips in different projects

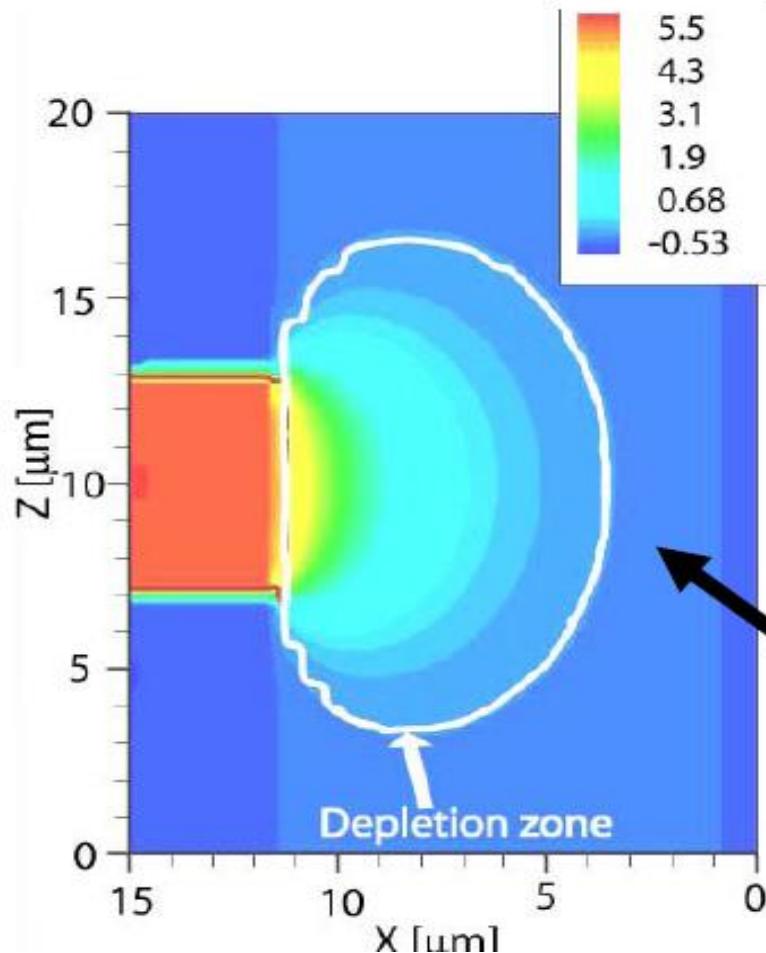


Chips development shared IPHC-IRFU through EUDET

Chips, pixel numbers, pitch

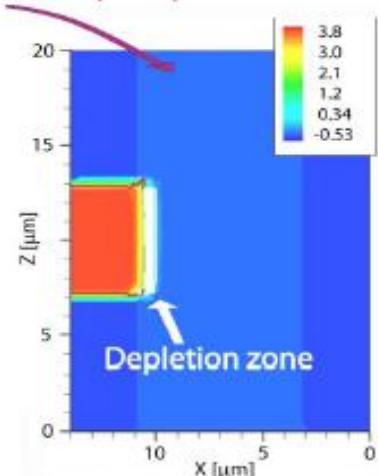


What change H R substrate ?



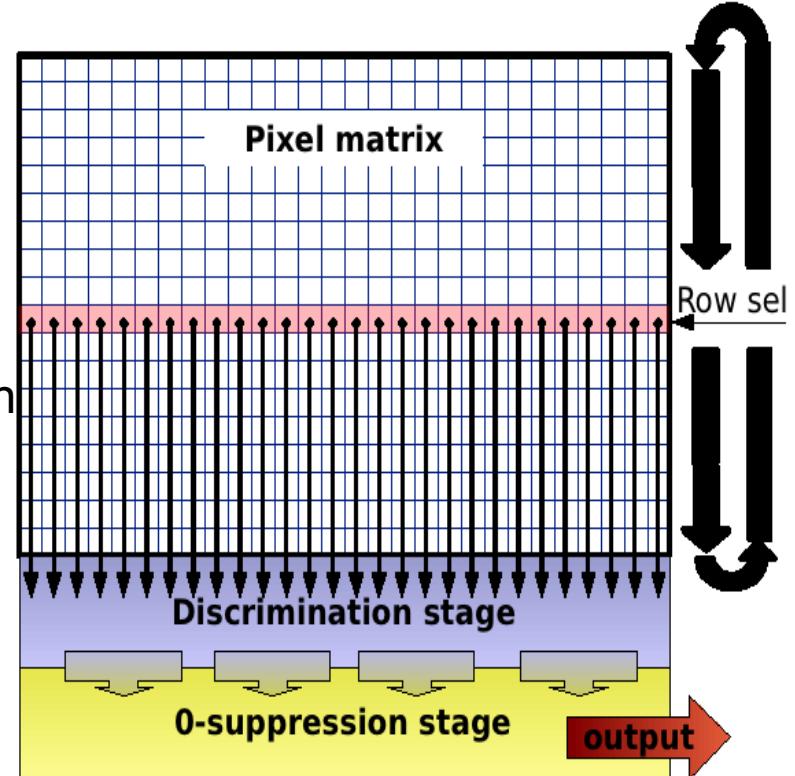
high resistivity ($1\text{k}\Omega\text{cm}$) P-epi:
size of depletion zone size is
comparable to the P-epi thickness!

For comparison: standard
CMOS technology, low
resistivity P-epi



TC / MIMOSA-26 : description

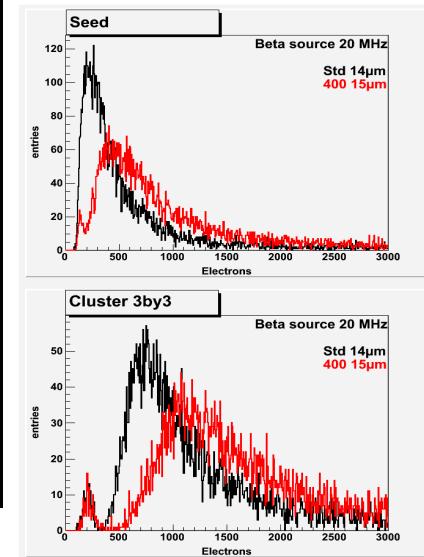
- ✗ CMOS 0.35 μm OPTO process
- ✗ Pixel Size : $18.4 \times 18.4 \mu\text{m}^2$
- ✗ Active Area :
 1152×576 pixels ($21.2 \times 10.6 \text{ mm}^2$)
- ✗ Rolling-shutter mode
 - 80 MHz clock → 112 μs integration
- ✗ One pixel contains:
 - Amplification
 - Double Sampling
- ✗ 1 discriminator per column with
 - Offset compensation
 - Correlated Double Sampling
- ✗ Parallel sparse data scan → Two memories
- ✗ Data compression factor x10 to 1000 depending on occupancy



Test Results on 2010 wafers

- 2010 : Standard EPI layer v.s. high resistivity EPI layer
⇒ Charge collection & S/N (Analogue output, Freq. 20 MHz)

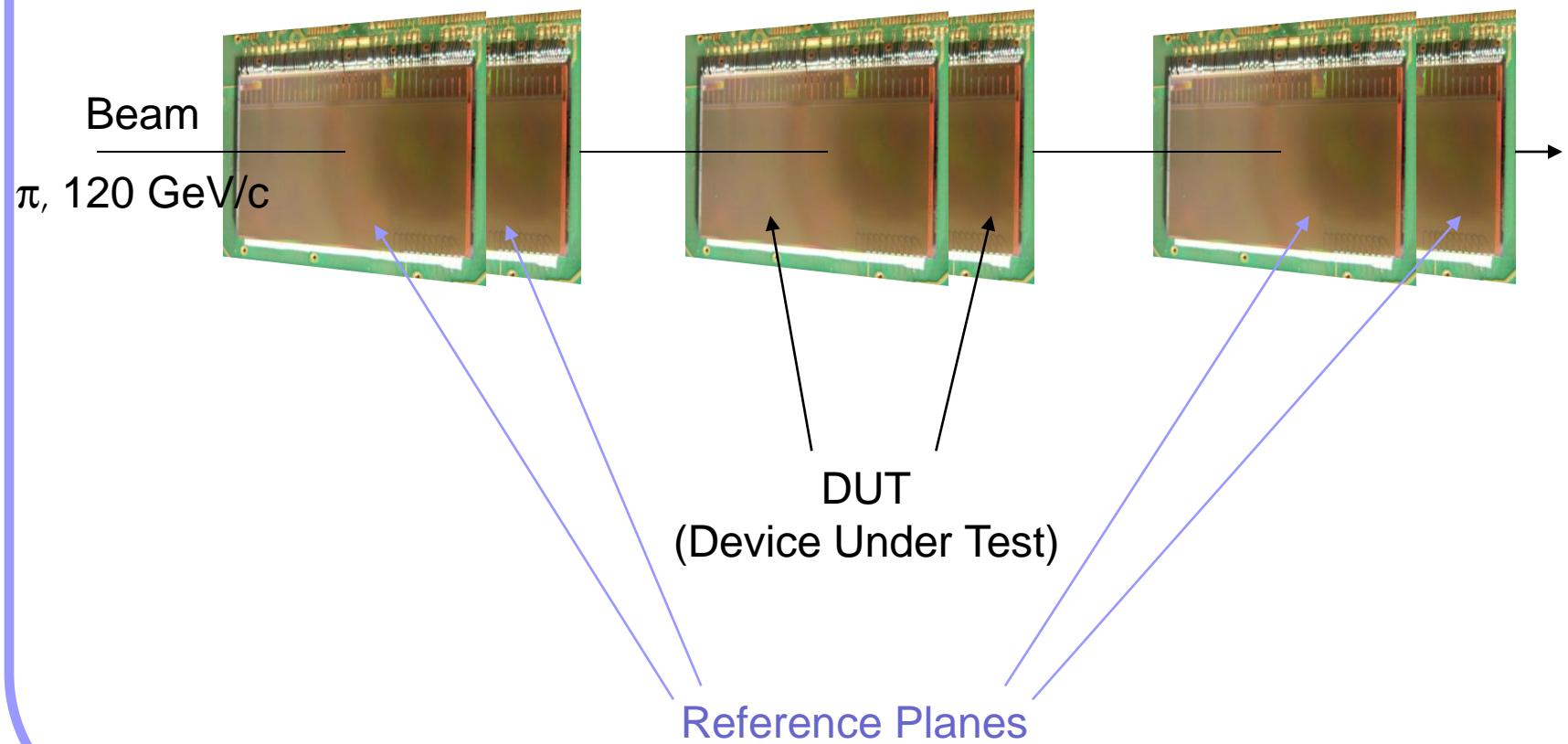
EPI layer	Standard (~10 Ω.cm) 14 μm			High resistivity (~400 Ω.cm)			
Charge Collection (⁵⁵ Fe source)	Seed	2x2	3x3	EPI	seed	2x2	3x3
	~21%	~ 54 %	~ 71 %	10 μm	~ 36 %	~ 85 %	~ 95 %
				15 μm	~ 31 %	~ 78 %	~ 91 %
				20 μm	~ 22 %	~ 57 %	~ 76 %
S/N at seed pixel (¹⁰⁶ Ru source)	~ 20 (230 e ⁻ /11.6 e ⁻)			10 μm	~ 35		
				15 μm	~ 41		
				20 μm	~ 36		



⇒ Discriminated Output characterization

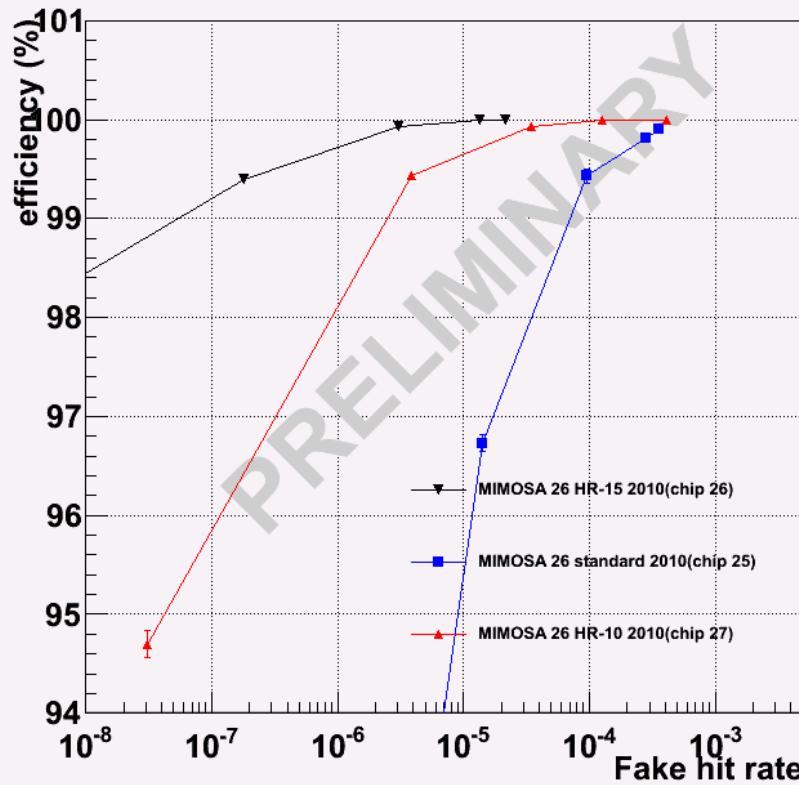
For standard epitaxial layer, the results on analogue outputs and discriminated ones are similar for the 2009 and 2010 wafers

TC / Mi-26 AHR Beam Test Set-up

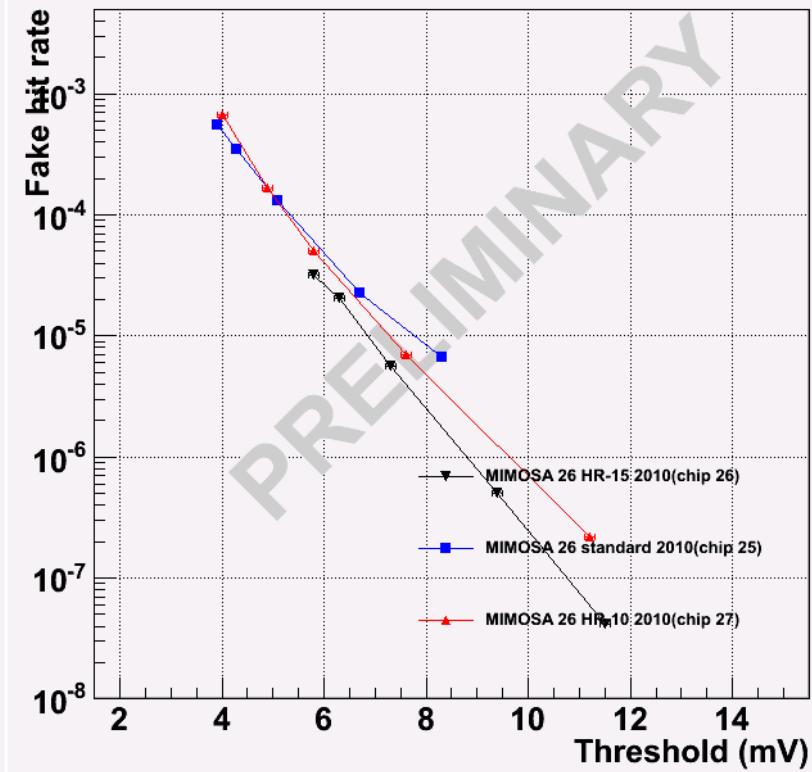


TC / Mi-26AHR TB Results (no irradiation)

Efficiency vs Fake hit rate

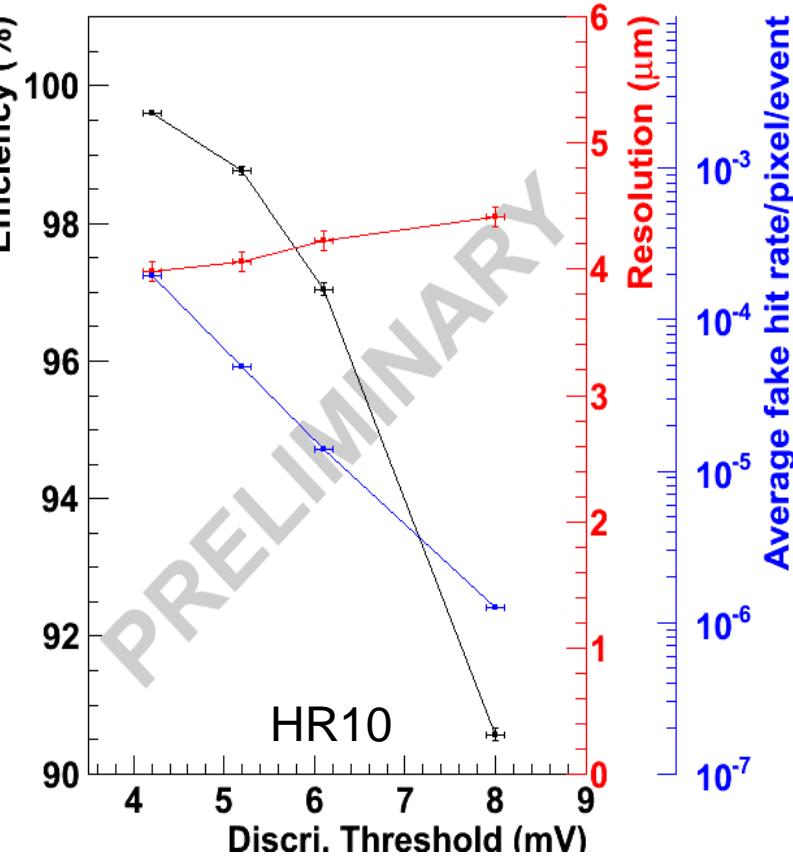
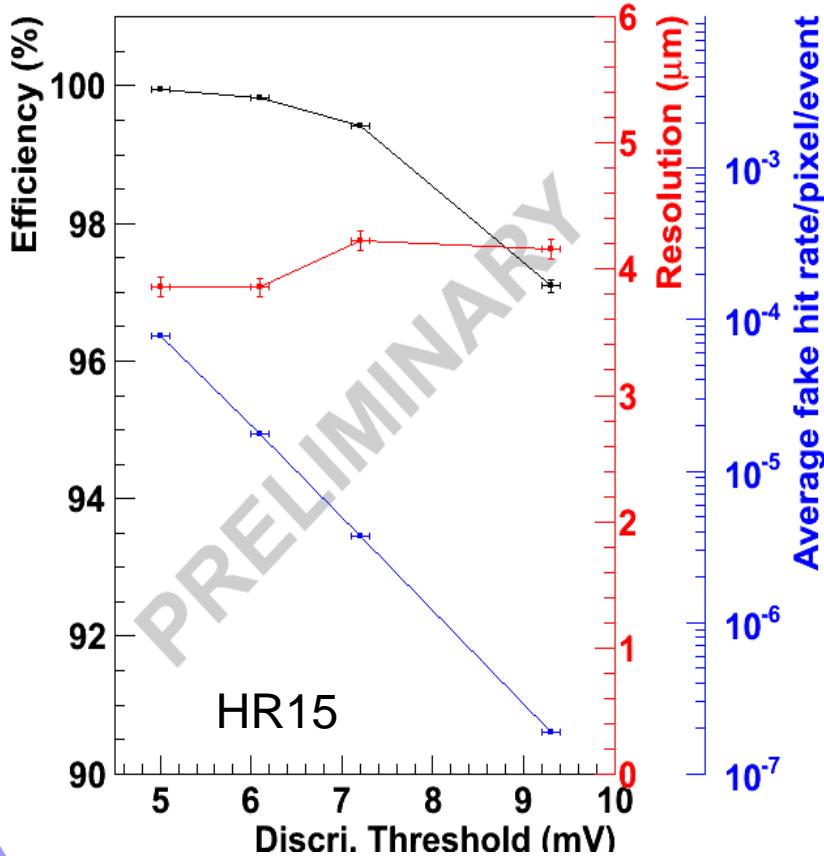


Fake hit rate (whole sensor) vs Threshold



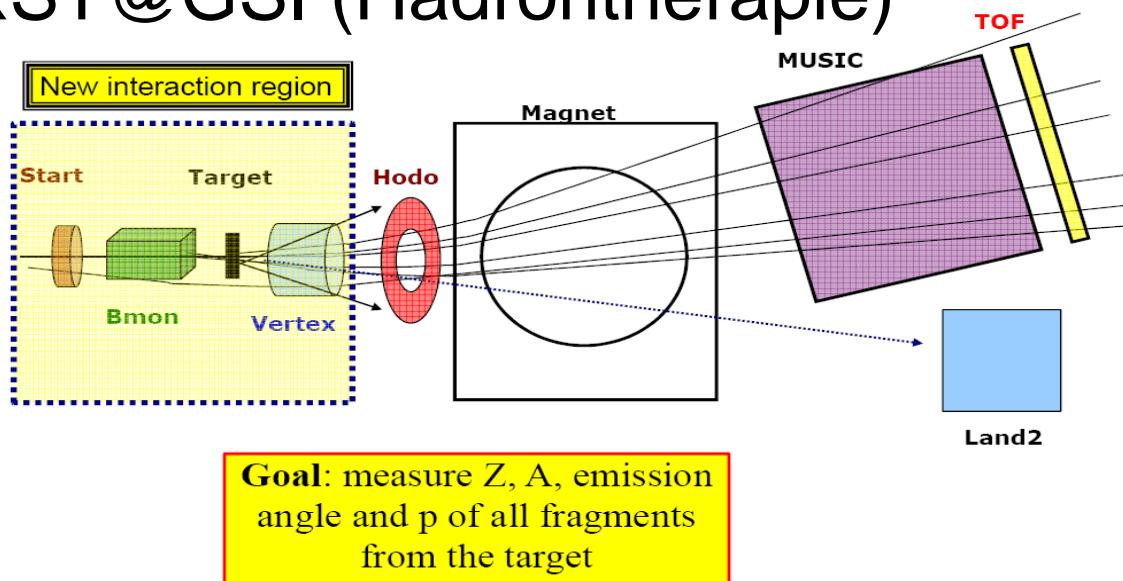
TC / Mi-26AHR TB Results : after 1.10^{13} N_{eq}

T ~ 0°C

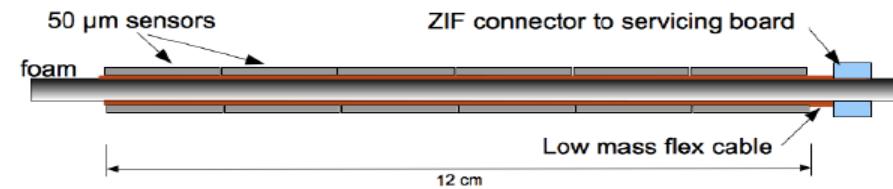


Extra-Use of TC

- FIRST@GSI (Hadrontherapie)



- Duplication of Eudet-telescope
- PLUME (Pixelated Ladder using Ultra-light Material Embedding)



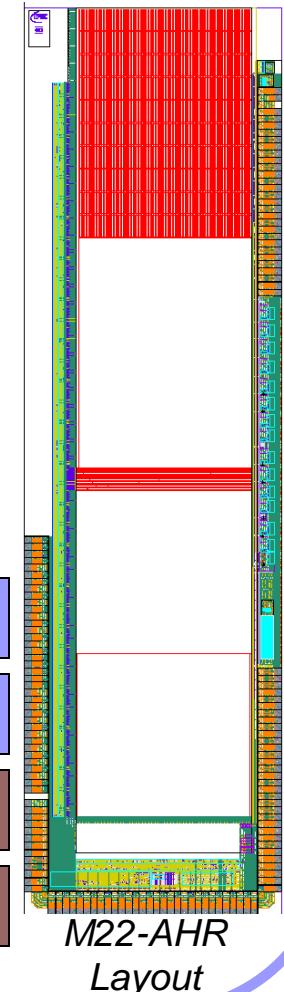
IDC / MIMOSA-22 AHR

Main parameters :

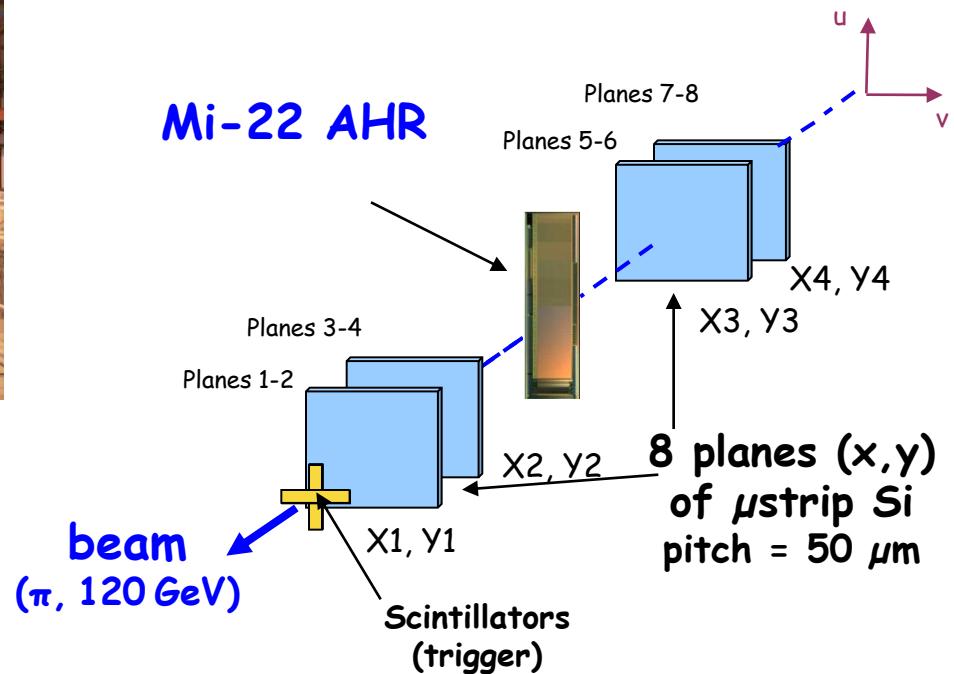
- **AMS-OPTO $0.35\mu\text{m}$**
- **Pixel Pitch : $18.4 / 20.7 \mu\text{m}$**
- **8 Analog test Outputs (4608 pixels)**
- **128 end-column discriminators (73728 pixels)**

Matrix : Sub-arrays with different diode surfaces

Pixel amelioration	Common Source	$18.4 / 20.7 \mu\text{m}$
New structure	CASCODE	$18.4 / 20.7 \mu\text{m}$
	Elongated pixels	$N \times 18.4 \mu\text{m}$
	Depletion volt. pixels	$20.7 \mu\text{m}$

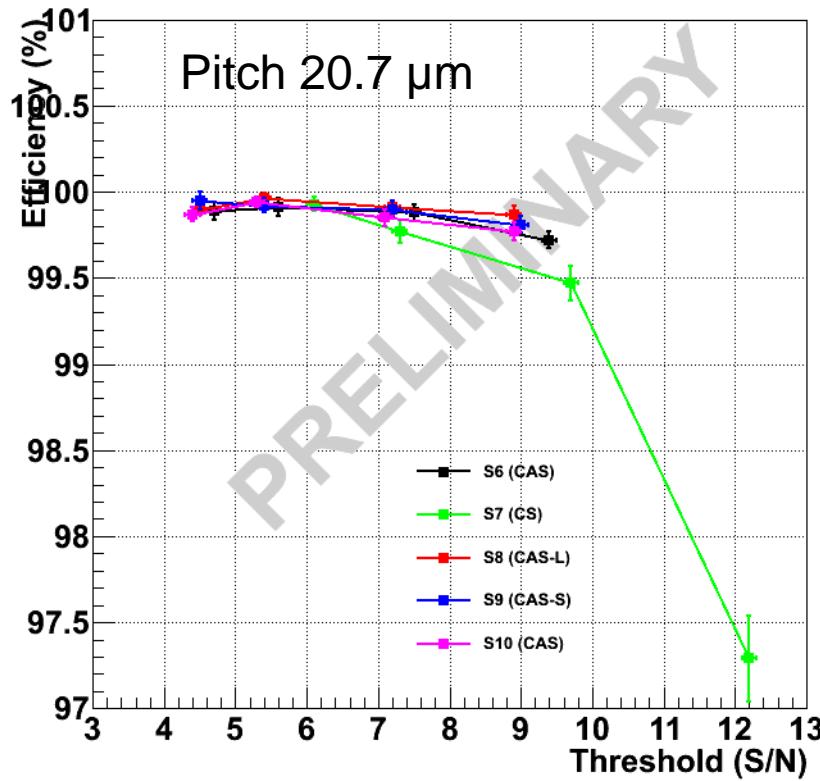


IDC / Mi-22 AHR beam test set-up

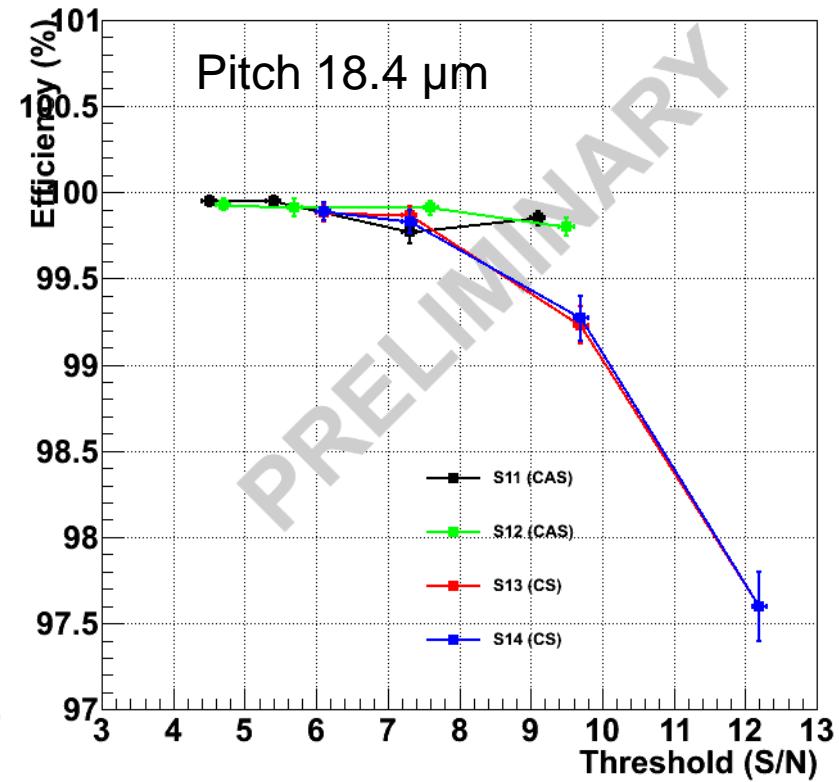


IDC August Test beam results

Efficiency vs Threshold

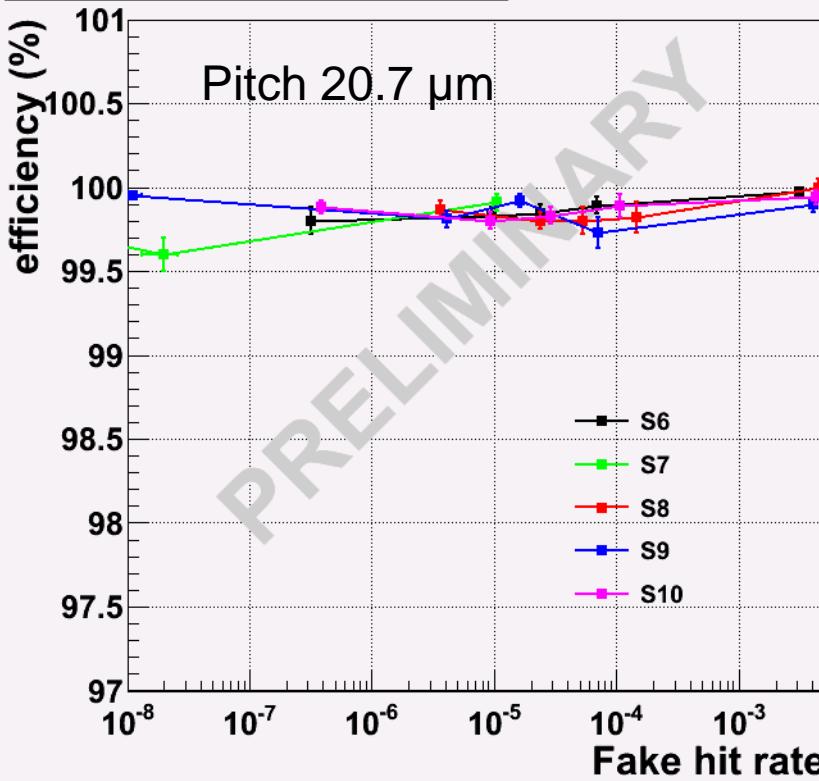


Efficiency vs Threshold

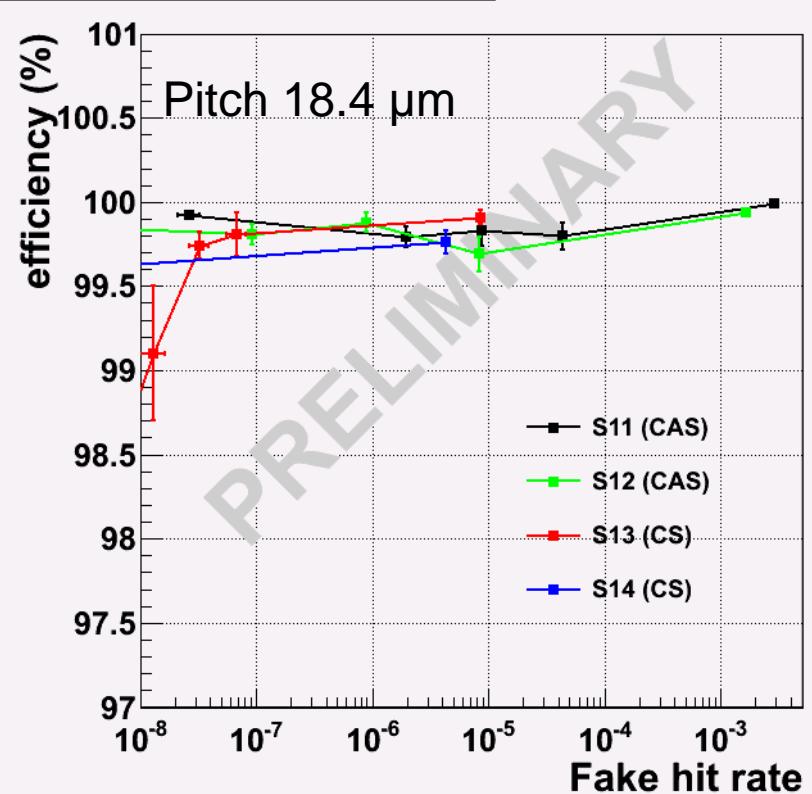


IDC August Test beam results (2)

Efficiency vs Fake hit rate

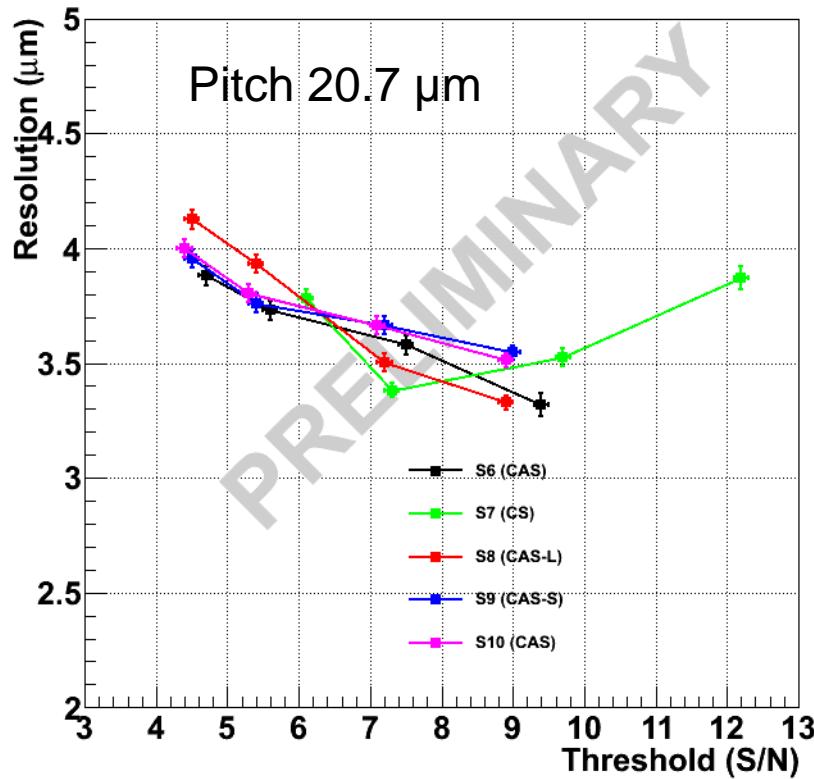


Efficiency vs Fake hit rate

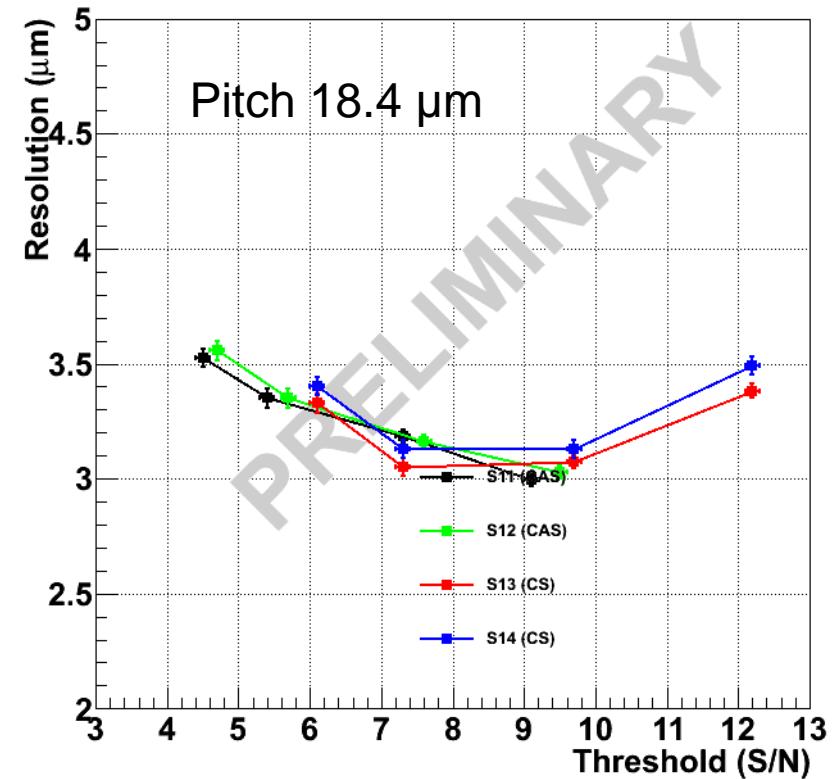


IDC August Test beam results (3)

Resolution vs Threshold



Resolution vs Threshold



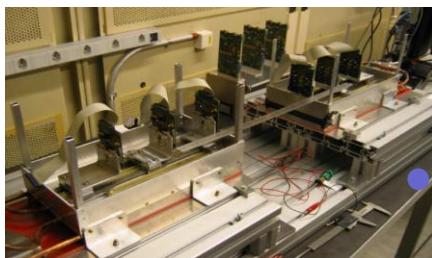
Mi-22 AHR beam test summary

- Pixel amelioration characterization :
 - No-irradiated
 - After a $3.10^{12} N_{eq}$ dose
 - After a 150 kRad dose
 - After a $3.10^{12} N_{eq} + 150\text{KRad}$ dose
 - New structures characterization :
 - Elongated pixels without irradiation
 - Depletion voltage pixels before / after $1.10^{13} N_{eq}$
- } at 15 and 30 °

Uses of TC / IDC architecture

EUDET 2007/2010

Beam Telescope

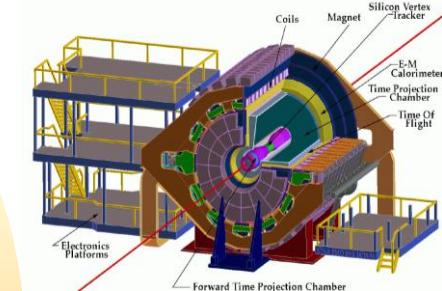


- **FP6 EUDET Project (DESY-Hamburg, Germany)**

- Surface $6 \times 2 \text{ cm}^2$
- Read-out speed A. $20 \text{ MHz} \rightarrow D.$ at 100 MHz
- Temp. & Power: No constraints

STAR 2010

Solenoidal Tracker at RHIC



- **STAR Experiment (RHIC – Brookhaven, USA)**

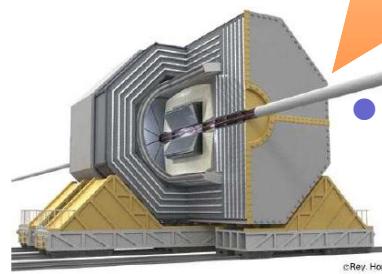
- Surface $\sim 1600 \text{ cm}^2$
- Temp. & Power $30^\circ\text{C}, \sim 100 \text{ mW/cm}^2$
- Read-out speed A. $50 \text{ MHz} \rightarrow D.$ up to 250 MHz

- **CBM Experiment (GSI – Darmstadt, Germany)**

- Surface $\sim 500 \text{ cm}^2$
- Read-out speed $D. 15 \times 10^9 \text{ pixels/sensor/s}$
- Rad Tol $1 \text{ MRad}, > 10^{13} N_{eq}/\text{cm}^2$

ILC >2012

International Linear Collider

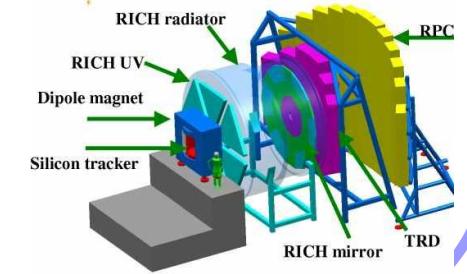


- **ILC Experiment**

- 5-6 layers of det. $\sim 3000 \text{ cm}^2$
- Read-out speed $D. 15 \times 10^9 \text{ pixels/sensor/s}$
- Temp. & Power $30^\circ\text{C}, \sim 100 \text{ mW/cm}^2$
- Rad Tol $\sim 300 \text{ kRad}, \sim 10^{12} N_{eq}/\text{cm}^2$

CBM 2012

Compressed Baryonic Matter



Uses of TC / IDC architecture (2)

- Eudet (FP6) → FP7
 - AIDA
 - HP2
- FOCAL (FOrward electromagnetic CALorimeter) for ALICE upgrade

Summary

- Investigation on new substrate (HR)
 - Study on 2 promising chips
 - Thanks to this new substrate, we expect to improve the radio-tolerance (TC / Mi-26 AHR after $1.10^{13}N_{eq}$)
- Use of the TC beyond Eudet project
 - First (hadrontherapie)
 - Telescope copies
 - STAR
 - AIDA telescope chips

● Back-up

Mi-22 AHR different sub-arrays

Pixel architecture	Pitch	Diode surface	Remarks	Number of Lines
Commun Source	18.4 µm	13 µm ²	L45	32
	20.7 µm	13 µm ²		32
CASCODE	18.4 µm	13 µm ²	L45	32
	20.7 µm	13 µm ² 18 µm ² 11 µm ²	L40	32
CASCODE (elongated pixels)	18.4 µm x2 18.4 µm x4	13 µm ²		16
SF+ CAS (depl. volt. pixels)	20.7 µm	13 µm ² 9 µm ² 9 µm ²	FD ELT T	32